|  | Application No.   | Applicant(s)   |                           |
|--|---|--|---------------------------|
| Notice of Allowability   | 10/705,707  | TRAN ET AL.  |                           |
|  | Examin r  | Art Unit   | ,                         |
|  | Tu-Tu Ho  | 2818   | A                         |
| The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313  | (OR REMAINS) CLOSED or other appropriate comm IGHTS. This application is                    | in this application. If not include<br>nunication will be mailed in due  | ed<br>course. <b>THIS</b> |
| 1. 🗵 This communication is responsive to Amendment filed 06/   | <u>11/2004</u> .  |  |                           |
| 2. X The allowed claim(s) is/are 1-10,12-17,19-24 and 26-42.   |   |  |                           |
| 3. $\boxtimes$ The drawings filed on <u>11 November 2003</u> are accepted by   | the Examiner.   |  |                           |
| <ul> <li>4. Acknowledgment is made of a claim for foreign priority una)</li> <li>All b) Some* c) None of the:</li> <li>1. Certified copies of the priority documents have</li> <li>2. Certified copies of the priority documents have</li> <li>3. Copies of the certified copies of the priority do</li> <li>International Bureau (PCT Rule 17.2(a)).</li> <li>* Certified copies not received:</li> </ul>                                       | e been received.<br>e been received in Applicati  | on No  | ition from the            |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.  |   | e a reply complying with the red   | quirements                |
| 5. A SUBSTITUTE OATH OR DECLARATION must be subm<br>INFORMAL PATENT APPLICATION (PTO-152) which give   |   |  | IOTICE OF                 |
| 6. CORRECTED DRAWINGS ( as "replacement sheets") must (a) including changes required by the Notice of Draftspers 1) hereto or 2) to Paper No./Mail Date (b) including changes required by the attached Examiner' Paper No./Mail Date  Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the state of the sheet in the state of the sheet in the state of the sheet. | son's Patent Drawing Revie<br><br>s Amendment / Comment on<br>l.84(c)) should be written on | or in the Office action of the drawings in the front (not the  | ə back) of                |
| <ol> <li>DEPOSIT OF and/or INFORMATION about the depo<br/>attached Examiner's comment regarding REQUIREMENT</li> </ol>   |   |  | Note the                  |
| Attachm nt(s)  1. ☐ Notice of References Cited (PTO-892)  2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)  3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date 02/05/2004  4. ☐ Examiner's Comment Regarding Requirement for Deposit of Biological Material  | 6. ☐ Interview S<br>Paper No<br>08), 7. ☐ Examiner's  | nformal Patent Application (PTo<br>Summary (PTO-413),<br>./Mail Date<br>s Amendment/Comment<br>s Statement of Reasons for Allo | ŕ                         |
| S  | David Nelms<br>Supervisory Patent Examiner<br>Technology Center 2800                        |  |                           |

1. Applicant's Amendment filed 06/11/2004 has been reviewed and placed of record in the file.

Allowable Subject Matter

2. Claims 1-10, 12-17, 19-24, and 26-42 (to be renumbered 1-39) are allowable over the prior art of record.

The following is an examiner's statement of reasons for allowance: The prior art of record fails to teach or render obvious a method of forming a memory cell having all exclusive limitations as recited in claims 1, 2, 4, 10, 12, 19, 26, 30-31, 33-40, and 42, characterized in that the conductive bit line is recessed below the uppermost surface of the base substrate by at least a first distance defined by the combined distances of a junction depth plus a depletion width of the transistor, or that forming a liner for a trench in a base substrate by thermally growing a first layer of oxide and depositing a second layer of oxide over the first layer of oxide; or forming a cap within a trench over a conductive bitline, the bitline at least within the trench and etched below an uppermost surface of a base substrate, the cap comprising a layer of nitride and a layer of insulating material over the nitride layer.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue

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fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for

Allowance."

3. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Tu-Tu Ho whose telephone number is (571) 272-1778. The

examiner can normally be reached on 6:30 am - 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, DAVID NELMS can be reached on (571) 272-1787. The fax phone numbers for the

organization where this application or proceeding is assigned are (703) 872-9306 for regular

communications and (703) 872-9306 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding

should be directed to the receptionist whose telephone number is (703) 308-1782.

Tu-Tu Ho

June 26, 2004

David Nelms
Supervisory Patent Examiner

Technology Center 2800